

#10/DWG  
2/22/02  
V. Vannal  
PATENT

Customer No. 22,852  
Attorney Docket No. 08038.0027



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Hikaru YOSHITAKA

Serial No.: 09/658,861

Filed: September 8, 2000

Group Art Unit: 2812

Examiner: Nguyen, H.

RECEIVED  
FEB 15 2002  
TECHNOLOGY CENTER 2800

For: SEMICONDUCTOR DEVICE AND  
METHOD OF MANUFACTURING  
THE SAME

Commissioner for Patents and Trademarks  
Washington, DC 20231

Sir:

Approved by  
change. m 4-29-02

**REQUEST FOR APPROVAL OF DRAWING CHANGE**

Subject to the approval of the Examiner, it is respectfully requested that Fig. 11 in the above-captioned application be amended by adding a "Prior Art" designation to the drawing as required by the Examiner in the Office Action dated August 15, 2001. The changes are indicated in red on the attached copy of the originally filed drawing.

Upon approval of the proposed changes, applicant respectfully requests that the submission of revised drawings be deferred until after a notice of allowance has issued.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW,  
GARRETT & DUNNER, L.L.P.

Dated: February 12, 2002

By:

*David W. Hill*

David W. Hill  
Reg. No. 28,220